

# Physics of Organic Semiconductors

*Edited by*  
*Wolfgang Brütting*



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# Introduction to the Physics of Organic Semiconductors

W. Brütting

## 1

### History

With the invention of the transistor around the middle of the last century, inorganic semiconductors like Si or Ge began to take over the role as dominant material in electronics from the before prevailing metals. At the same time, the replacement of vacuum tube based electronics by solid state devices initiated a development which by the end of the 20<sup>th</sup> century has lead to the omnipresence of semiconductor microelectronics in our everyday life. Now at the beginning of the 21<sup>st</sup> century we are facing a new electronics revolution that has become possible due to the development and understanding of a new class of materials, commonly known as *Organic Semiconductors*. The enormous progress in this field has been driven by the expectation to realize new applications, such as large area, flexible light sources and displays, low-cost printed integrated circuits or plastic solar cells from these materials.

Strictly speaking organic semiconductors are not new. The first studies of the dark and photoconductivity of anthracene crystals (a prototype organic semiconductor, see e.g. [1]) date back to the early 20<sup>th</sup> century [2,3]. Later on, triggered by the discovery of electroluminescence in the 1960s [4,5], molecular crystals were intensely investigated by many researchers. These investigations could establish the basic processes involved in optical excitation and charge carrier transport (for a review see e.g. [6,7]). Nevertheless, in spite of the principal demonstration of an organic electroluminescent diode incorporating even an encapsulation similar to the ones used in nowadays commercial display applications [8], there were several draw-backs preventing practical use of these early devices. For example, neither high enough current densities and light output nor sufficient stability could be achieved. The main obstacles were the high operating voltage as a consequence of the crystal thickness in the micrometre to millimetre range together with the difficulties in scaling up crystal growth as well as preparing stable and sufficiently well-injecting contacts to them.

Since the 1970s the successful synthesis and controlled doping of conjugated polymers [9] established the second important class of organic semiconductors which was honoured with the Nobel Prize in Chemistry in the year 2000. Together with organic photoconductors (molecularly doped polymers) these conducting poly-

mers have initiated the first applications of organic materials as conductive coatings [10] or photoreceptors in electrophotography [11].

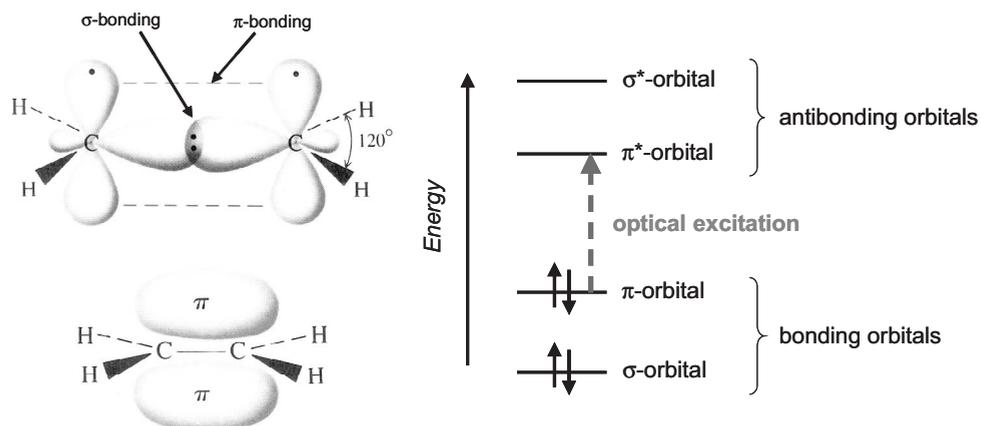
The interest in undoped organic semiconductors revived in the 1980s due to the demonstration of an efficient photovoltaic cell incorporating an organic hetero-junction of p- and n-conducting materials [12] as well as the first successful fabrication of thin film transistors from conjugated polymers and oligomers [13-15]. The main impetus, however, came from the demonstration of high-performance electroluminescent diodes from vacuum-evaporated molecular films [16,17] and from conjugated polymers [18,19]. Owing to the large efforts of both academic and industrial research laboratories during the last 15 years, organic light-emitting devices (OLEDs) have progressed rapidly and meanwhile lead to first commercial products incorporating OLED displays [20]. Other applications of organic semiconductors e.g. as logic circuits with organic field-effect transistors (OFETs) or organic photovoltaic cells (OPVCs) are expected to follow in the near future (for an overview see e.g. [21]).

## 2

### Materials

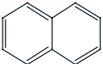
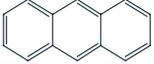
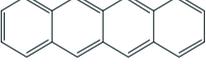
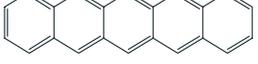
As already mentioned above, there are two major classes of organic semiconductors: low molecular weight materials and polymers. Both have in common a conjugated  $\pi$ -electron system being formed by the  $p_z$ -orbitals of  $sp^2$ -hybridized C-atoms in the molecules (see Fig. 1). As compared to the  $\sigma$ -bonds forming the backbone of the molecules, the  $\pi$ -bonding is significantly weaker. Therefore, the lowest electronic excitations of conjugated molecules are the  $\pi$ - $\pi^*$ -transitions with an energy gap typically between 1.5 and 3 eV leading to light absorption or emission in the visible spectral range. As shown in Table 1 for the family of the polyacenes the energy gap can be controlled by the degree of conjugation in a molecule. Thus chemistry offers a wide range of possibilities to tune the optoelectronic properties of organic semiconducting materials. Some prototype materials which are also discussed in this book are given in Fig. 2.

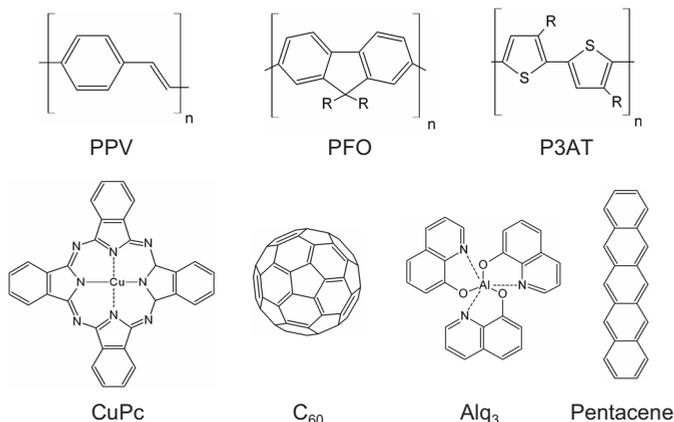
An important difference between the two classes of materials lies in the way how they are processed to form thin films. Whereas small molecules are usually deposited from the gas phase by sublimation or evaporation, conjugated polymers can only be processed from solution e.g. by spin-coating or printing techniques. Additionally, a number of low-molecular materials can be grown as single crystals allowing intrinsic electronic properties to be studied on such model systems (see e.g. [23] or [24] for an overview of the different classes of materials). The controlled growth of highly ordered thin films either by vacuum deposition or solution processing is still subject of ongoing research, but will be crucial for many applications (see e.g. [25]).



**Figure 1** Left:  $\sigma$ - and  $\pi$ -bonds in ethene, as an example for the simplest conjugated  $\pi$ -electron system. The right viewgraph shows the energy levels of a  $\pi$ -conjugated molecule. The lowest electronic excitation is between the bonding  $\pi$ -orbital and the antibonding  $\pi^*$ -orbital (adopted from [22]).

**Table 1** Molecular structure of the first five polyacenes, together with the wavelength of the main absorption peak (taken from [7]).

Molecule	Structure	Absorption Maximum
Benzene		255 nm
Naphthalene		315 nm
Anthracene		380 nm
Tetracene		480 nm
Pentacene		580nm



**Figure 2** Molecular structure of some prototype organic semiconductors: PPV: poly(p-phenylenevinylene), PFO: polyfluorene, P3AT: poly(3-alkylthiophene), Alq<sub>3</sub>: tris(8-hydroxyquinoline)aluminium, fullerene C<sub>60</sub>, CuPc: Cu-phthalocyanine, pentacene.

### 3

#### Basic Properties of Organic Semiconductors

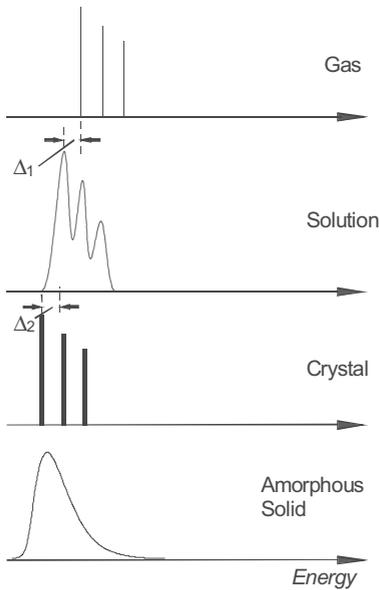
The nature of bonding in organic semiconductors is fundamentally different from their inorganic counterparts. Organic molecular crystals are van der Waals bonded solids implying a considerably weaker intermolecular bonding as compared to covalently bonded semiconductors like Si or GaAs. The consequences are seen in mechanical and thermodynamic properties like reduced hardness or lower melting point, but even more importantly in a much weaker delocalization of electronic wavefunctions among neighbouring molecules, which has direct implications for optical properties and charge carrier transport. The situation in polymers is somewhat different since the morphology of polymer chains can lead to improved mechanical properties. Nevertheless, the electronic interaction between adjacent chains is usually also quite weak in this class of materials.

#### 3.1

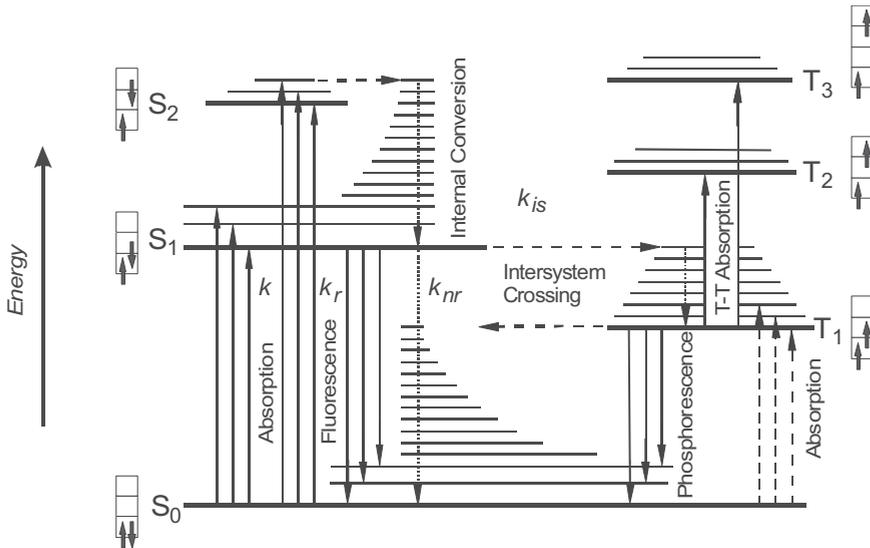
##### Optical Properties

Owing to the weak electronic delocalization, to first order the optical absorption and luminescence spectra of organic molecular solids are very similar to the spectra in the gas phase or in solution (apart from the trivial solvent shift). In particular, intramolecular vibrations play an important role in solid state spectra and often these vibronic modes can be resolved even at room temperature. Thus the term “oriented gas” is sometimes used for molecular crystals. Nevertheless, solid state spectra can differ in detail with respect to selection rules, oscillator strength and energetic posi-

tion; moreover, due to the crystal structure or the packing of polymer chains a pronounced anisotropy can be found. Additionally disordered organic solids usually show a considerable spectral broadening. This is schematically shown in Fig. 3.

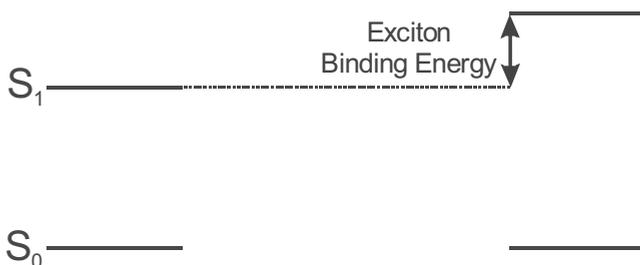
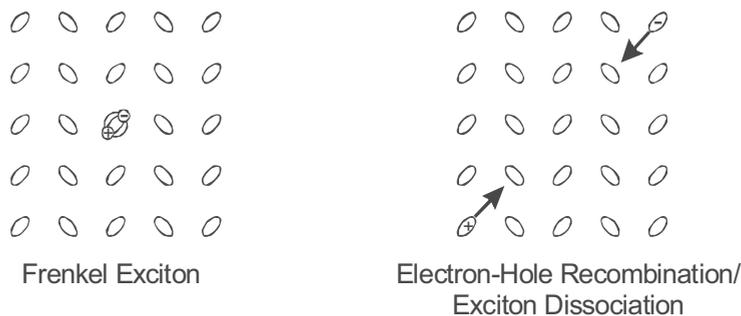


**Figure 3** Schematical representation of optical spectra of organic molecules in different surroundings.  $\Delta_1$  and  $\Delta_2$  denote the respective solvent shift in solution and solid state.



**Figure 4** Energy level scheme of an organic molecule (left: singlet manifold, right: triplet manifold). Arrows with solid lines indicate radiative transitions, those with broken lines nonradiative transitions (taken from [7]). Typical lifetimes of the  $S_1$  state are in the range

1...10 ns. Triplet lifetimes are usually in the millisecond range for pure aromatic hydrocarbons, but can be considerably shorter in molecules incorporating heavy atoms, like e.g. Pt or Ir.



**Figure 5** The energetic difference between an excited state sitting on one molecule (sometimes called a Frenkel exciton) and a pair of uncorrelated negative and positive carriers sitting on different molecules far apart defines the exciton binding energy. A simple estimation

as the Coulomb energy of an electron-hole pair localized at a distance of about 10 Å in a medium with a dielectric constant of 3 yields a value of about 0.5 eV for the exciton binding energy.

As a consequence of this weak electronic delocalization, organic semiconductors have two important peculiarities as compared to their inorganic counterparts. One is the existence of well-defined spin states (singlet and triplet) like in isolated molecules which has important consequences for the photophysics of these materials (see Fig. 4). However, since intersystem crossing is a weak process, this also sets an upper limit for the electroluminescence quantum efficiency in OLEDs. A second important difference originates from the fact that optical excitations (“excitons”) are usually localized on one molecule and therefore have a considerable binding energy of typically 0.5 to 1 eV. Thus in a photovoltaic cells this binding energy has to be overcome before a pair of independent positive and negative charge carriers is generated (see Fig. 5).

### 3.2

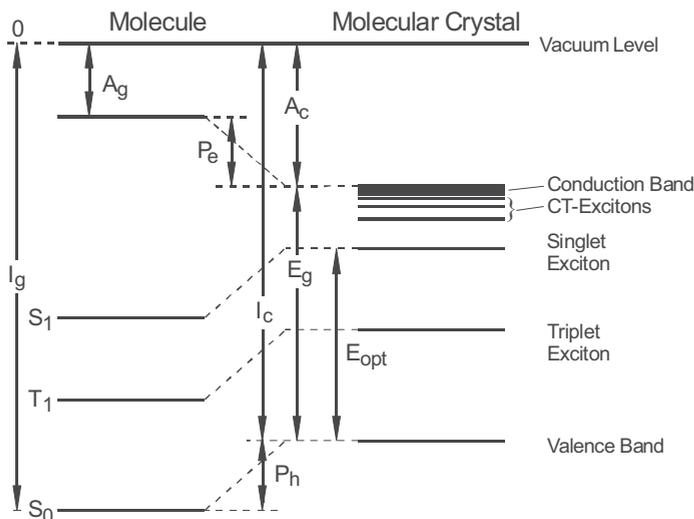
#### Charge Carrier Transport

When transport of electrons or holes in an organic molecular solid is considered, one has to bear in mind that this involves ionic molecular states. E.g. in order to create a hole, an electron has to be removed to form a radical cation  $M^+$  out of a neutral molecule  $M$ . This defect electron can then move from one molecule to the

next. In the same way, electron transport involves negatively charged radical ions  $M^{\ominus}$ . (Qualitatively, the same arguments hold for polymers, however, in this case charged states are usually termed positive or negative polarons.) As compared to isolated molecules in the gas phase, these ionic states are stabilized in the solid by polarization energies leading to an energy level scheme as shown in Fig. 6. From this picture one can clearly see that due to the already mentioned exciton binding energy the optical gap between the ground state and the first excited singlet state is considerably less than the single particle gap to create an uncorrelated electron-hole pair. In going from molecular crystals to disordered organic solids one also has to consider locally varying polarization energies due to different molecular environments which lead to a Gaussian density of states for the distribution of transport sites as shown in Fig. 7.

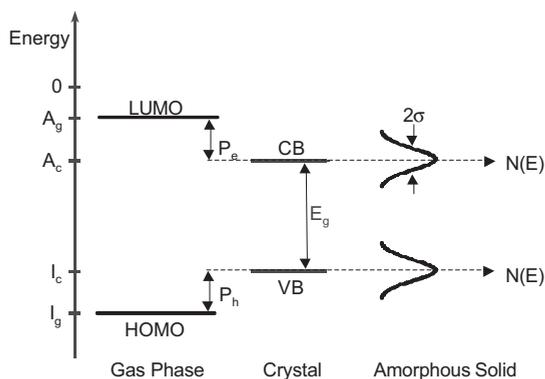
Thus, depending on the degree of order the charge carrier transport mechanism in organic semiconductors can fall between two extreme cases: band or hopping transport. Band transport is typically observed in highly purified molecular crystals at not too high temperatures. However, since electronic delocalization is weak the bandwidth is only small as compared to inorganic semiconductors (typically a few  $kT$  at room temperature only). Therefore room temperature mobilities in molecular crystals reach only values in the range 1 to 10  $\text{cm}^2/\text{Vs}$  [27]. As a characteristic feature of band transport the temperature dependence follows a power law behaviour

$$\mu \propto T^{-n} \text{ with } n = 1 \dots 3 \quad (1)$$



**Figure 6** Energy levels of an isolated molecule (left) and a molecular crystal (right).  $I_g$  and  $A_g$  denote the ionization potential and electron affinity in the gas phase,  $I_c$  and  $A_c$  the respective quantities in the crystal. Due to the polarization energies  $P_h$  and  $P_e$  charged states are

stabilized in the crystal.  $E_g$  is the single particle gap being relevant for charge carrier generation, whereas  $E_{opt}$  denotes the optical gap measured in absorption and luminescence. Their difference is the so-called exciton binding energy. (Figure adopted from [7]).



**Figure 7** Energy levels of an isolated molecule (left), a molecular crystal (middle) and an amorphous solid (right). The width of the Gaussian density of states in an amorphous solid is typically in the range of  $\sigma = 80 \dots 120$  meV, whereas the band width in molecular crystals is less than 100 meV. (Figure adopted from [26]).

upon going to lower temperature. However, in the presence of traps significant deviations from such a behaviour are observed [28].

In the other extreme case of an amorphous organic solid hopping transport prevails which leads to much lower mobility values (at best around  $10^{-3}$  cm<sup>2</sup>/Vs, in many cases however much less). Instead of a power law the temperature dependence then shows an activated behaviour and the mobility also depends on the applied electric field:

$$\mu(F, T) \propto \exp(-\Delta E/kT) \cdot \exp(\beta\sqrt{F}/kT) \quad (2)$$

Depending on the model slightly different temperature dependencies for the mobility have been suggested (for a review see [11]). Furthermore, space-charge and trapping effects as well as details of the charge carrier injection mechanism have to be considered for describing electrical transport in organic solids [29-33].

On a macroscopic level, the current through a material is given by the charge carrier density  $n$  and the carrier drift velocity  $v$ , where the latter can be expressed by the mobility  $\mu$  and the electric field  $F$ :

$$j = env = en\mu F \quad (3)$$

One has to bear in mind that in contrast to metals this is usually not a linear relation between  $j$  and  $F$  since both the carrier density and mobility can depend on the applied field. According to this equation, apart from the field, the two parameters  $n$  and  $\mu$  determine the magnitude of the current. Thus it is instructive to compare their typical values with inorganic semiconductors and discuss different ways to control them.

As already discussed above, the mobility strongly depends on the degree of order and purity in organic semiconductors and therefore to a great deal on the preparation and growth conditions. It can reach values of 1-10 cm<sup>2</sup>/Vs in molecular crystals (see the contribution of de Boer et al. in this book), but values of only 10<sup>-5</sup> cm<sup>2</sup>/Vs in amorphous materials are also not unusual. The highest mobility values achievable in thin films are nowadays comparable to amorphous silicon which is of course orders of magnitude less than crystalline Si [34-36].

The second parameter is the charge carrier density  $n$ . The intrinsic carrier density in a semiconductor with an energy gap  $E_g$  and an effective density of states  $N_0$  (which is strictly speaking the product of valence and conduction band densities) is given by:

$$n_i = N_0 \cdot \exp(-E_g/2kT) \quad (4)$$

Taking typical values for an organic semiconductor with  $E_g=2.5$  eV and  $N_0=10^{21}$  cm<sup>-3</sup> leads to a hypothetical carrier density of  $n_i=1$  cm<sup>-3</sup> at room temperature, which is of course never reachable since impurities will lead to much higher densities in real materials. Nevertheless, the corresponding value for Si ( $E_g=1.12$  eV and  $N_0=10^{19}$  cm<sup>-3</sup>) is with  $n_i=10^{10}$  cm<sup>-3</sup> many orders of magnitude higher, which demonstrates that organic semiconductors should have extremely low conductivity if they are pure enough.

In order to overcome the limitations posed by the low intrinsic carrier density, different means to increase the carrier density in organic semiconductors can be applied:

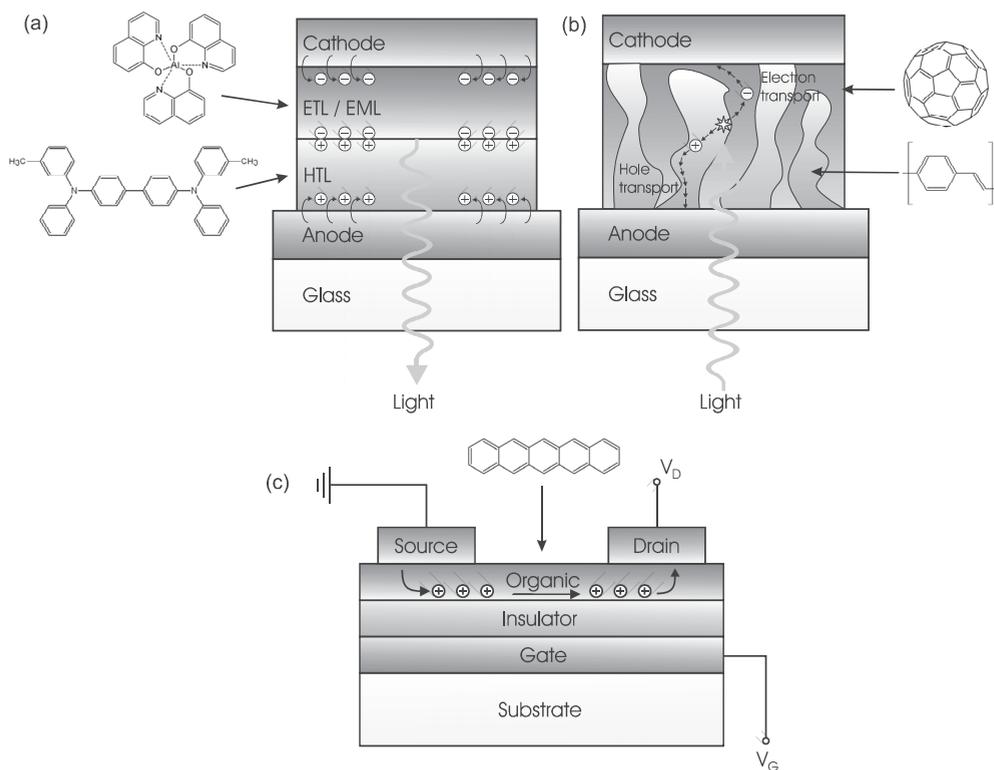
1. (electro-)chemical doping,
2. carrier injection from contacts,
3. photo-generation of carriers, and
4. field-effect doping.

In the following section these methods will be briefly discussed together with their realization in different device structures.

### 3.3

#### Device Structures and Properties

Controlled doping has been one of the keys for the success of semiconductor microelectronics. There have been efforts to use tools like ion implantation doping also for organic semiconductors [37], however, due to the concomitant ion beam damages and the need for sophisticated equipment this method is probably not compatible with organic devices. Other techniques, like chemical doping by adding strong electron donors or acceptors as well as by electrochemical means have been successfully applied [38,39]. At this point one should also mention that often unintentional doping of organic materials already occurs during the synthesis or handling of the materials since in many cases ambient oxygen causes p-type doping of organic materials. Thus at present, controlled doping in organic semiconductors is still in its infancy



**Figure 8** Different types of organic semiconductor devices are shown. (a) Organic light-emitting diode (OLED): Typically, a heterolayer structure is used, where HTL stands for hole transport layer and ETL for electron transport layer, EML denotes the emission layer. Instead of the displayed combination of a triphenylamine derivative and Alq<sub>3</sub>, polymeric OLEDs usually employ a conductive polymer (PEDOT:PSS) together with luminescent polymers like PPV or PFO derivatives. (b) Organic

photovoltaic cell (OPVC): The so-called bulk-heterojunction devices usually consist of a mixture of soluble PPV (or P3AT) and fullerene derivatives. Alternatively, mixed layers of evaporated small molecules like CuPc and C<sub>60</sub> can be used. (c) Organic field-effect transistor (OFET): Prototypical materials in p-channel OFETs are pentacene as a low molecular weight material and P3AT as a conjugated polymer, respectively. Among others, e.g. C<sub>60</sub> can be employed in n-channel transistors.

and needs further investigations to employ it as a powerful tool for organic electronics.

Injection of charge carriers from contacts is essentially the process that governs device operation in organic light-emitting devices (OLEDs) (see Fig. 8a). This requires low energetic barriers at the metal-organic interfaces for both contacts to inject equally high amounts of electrons and holes, which is required for a balanced charge carrier flow. Thus the interface energetic structure plays a very crucial role for achieving efficient OLEDs. Another process that comes into play is space-charge limitation of the current. Due to relatively high electric fields being applied to